

imiD 2022

The 22nd International Meeting on Information Display
August 23-26, 2022 / BEXCO, BUSAN, KOREA

Session Title:	50. Oxide TFT 3
Session Date:	August 26 (Fri.), 2022
Session Time:	11:00-12:30
Session Room:	Room B (214~216)
Session Chair(s):	Prof. Myung-Gil Kim (Sungkyunkwan Univ., Korea)

[B50-1] [Invited]	11:00-11:25
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Development of High Mobility Oxide TFTs for AMOLEDs

Joon Seok Park, Jun Hyung Lim, Taewook Kang, and Changhee Lee (Samsung Display Co., Ltd., Korea)

[B50-2] [Invited]	11:25-11:50
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Progressive Manufacturing Technology in LTPO

Tae-Hyoung Moon, Ki-Tae Kim, Sung-Jin Lee, Kwon-Shik Park, Jeom-Jae Kim, and Soo-Young Yoon (LG Display Co., Ltd., Korea)

[B50-3] [Invited]	11:50-12:15
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A Thin-Film Transistor with No Apparent Channel for High Pixel Density Displays

Jiawei Zhang (Shandong Univ., China), Josh Wilson (Univ. of Manchester, UK), and Aimin Song (Shandong Univ., China)

[B50-4]	12:15-12:30
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Impact of Precursor Aging and Relative Humidity on the Electric Performance of Solution-Deposited Amorphous Gallium Oxide Thin Film Transistors

Diki Purnawati, Juan Paolo Bermundo, and Yukiharu Uraoka (NAIST, Japan)